

Controlling surface-enhanced charge screening to realize single-molecule sensing with silicon FET sensors



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1. Introduction

Large-scale single-molecule sensing to enable & boost applications in the life sciences (e.g. SMRT sequencing)

Silicon **Field-Effect Transistor (FET) sensor**:

- Real-time **charge-based sensing** of biomolecules and/or ions
- Paragon of **embeddable & scalable** technology

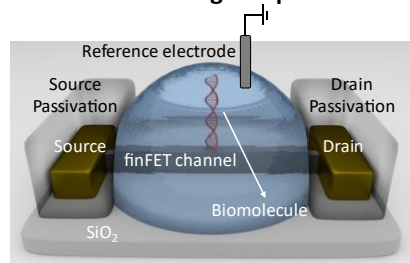
→ **Unprecedented throughput & parallelism**

No single-molecule detection achieved

Main **sensitivity-limiting** factor is electrolyte **charge screening**

- Enhanced by charged and pH-sensitive oxide surface sites

→ **non-linear screening** and **pH feedback effect**



2. FET sensor modeling

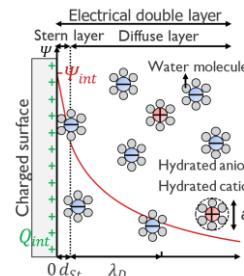
a. Non-linear screening

- Formation of **electrical double layer** at charged entity: screening by near-exponential distribution of ions
- **Increased ion concentration (c_{\pm})** in diffuse layer **enhances electrolyte screening**

Bikerman model:

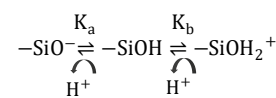
$$c_{\pm} = \frac{c_0 \exp\left(\frac{\mp q\psi}{kT}\right)}{1 + 4a^3 c_0^2 \sinh^2\left(\frac{q\psi}{2kT}\right)}$$

c_0 is bulk ion conc.



b. pH feedback effect

- **Biomolecule charge** alters local proton conc. $[H^+]_{int}$ or **pH** at the FET surface
- **pH-sensitive** oxide surface sites induce a **counter charge**



For SiO_2 :

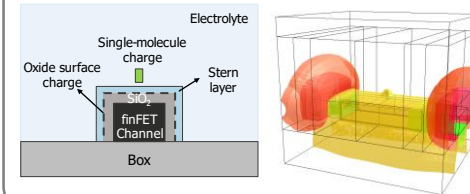
$$K_a = \frac{[H^+]_{int} \Gamma_{SiO^-}}{\Gamma_{SiOH}} \quad pK_a = 4.5$$

$$N_t = \Gamma_{SiOH} + \Gamma_{SiO^-} = 4 \times 10^{13} \text{ cm}^{-2}$$

3. Single-molecule TCAD simulation

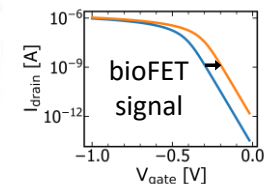
a. finFET with discrete biomolecule

- 15bp dsDNA = 30 charges
- 1.5 mM salinity and pH 7



b. Simulation of single-molecule SNR

- **Signal** is ΔV_g of I_d - V_g curve due to charge of biomolecule
- **Noise** is $\Delta V_{trap} \sqrt{D_{trap} A_{eff}}$



D_{trap} = Calibr. oxide trap density
 A_{eff} = effective FET surface area

4. Results and discussion

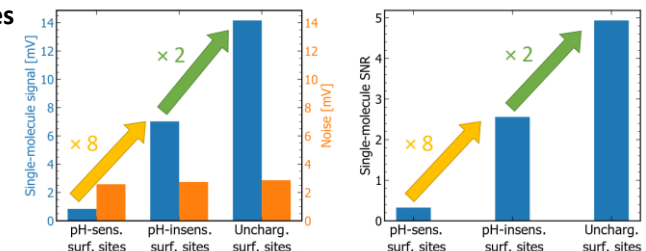
pH-insensitive surface sites

- **8x boost** in signal and SNR

Uncharged surface sites

- Extra **2x boost** in signal and SNR

Noise unaffected



To **boost FET single-molecule sensitivity**, one must select a gate oxide with **lowly-charged** and **pH-insensitive** surface sites